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CORPORATE PROFILE 2023

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History and Highlights

Founded	1980	 Introduced the first quartz constant temperature bath and dump rinser which eventually emerged as an industry standard.
Product Development	1982-1985	 Developed the following product lines: C Series - Condensing bath CF Series - Chemical dispensing bath F Series - Filtration of HF acid and BOE I Series - Automatic chemical injection with a quartz bath N Series - Temperature control RC Series - Temperature control circulator
Nitride Etch	1985	 Introduced Na Series for silicon nitride etching.
Filtration	1988	 Introduced ultra-high temp filter clean/strip system.
Product Introductions	1992	 Introduced the following products: Rd Series - New technology for rinse systems CFa Series - New advances in chemical injection QFa Series - Quartz filtration to 150°C with reduced particle counts and acid consumption Apex Series - Stand-alone acid recirculation and filtration system TF Series - Teflon® filter etch bath RQ - Quartz ultra clean wafer rinse system SF Series - Stainless steel filter etch bath for solvent-based stripping
	1993-1994	 Introduced the following products: Nb Series - Silicon Nitride Etch bath with positive purge seal QFN Series - Quartz Filtration Nitride etch bath RCd Series - CFC-tree temp. control circulator IR Series - Infrared Quartz In-line Moduheater
	1995	 Introduced the following products: IR Series - 3-6 kW Infrared high temperature heaters QR Series - Quartz infrared heated bath
	1996	 Introduced the following products: C4000 - Integrator Series touch screen controller HS Series Stand-Alone Nitride Etch Bath w/ IR heater and PLC control
	1997	 Introduced the following product: MS Series Hi-Megasonic Cleaner with a multitude of configurations including dump rinsers, quartz heated megasonic (up to 130°C) with both direct and indirect methods of operation
	1998	Introduced the following product:RCe Series - Upgraded RCd Series
	1999	 Subsidiary joins Modutek: Pollution Control Labs (PCL) is now Modutek. We have joined forces to better control our environmental equipment and chemical handling capabilities.
	2000	 Purchased CNC overhead router for advanced fabrication capacity Updated engineering software for 3D modeling QR Series - Quartz infrared heated bath
	2002	 Purchased Sysmax Inc. for semi-auto capability C4000 - Integrator Series touchscreen controller HS Series Stand-Alone Nitride Etch Bath w/ IR heater and PLC control

2003	•	Introduced a complete neutralization line
2004	•	Started our mechanical contract department with two major contractors Built a neutralization system for a large bioscience corporation
2005	•	Manufactured a fully automated process tool Manufactured a semi-automated cleaning tool Concentrated on system integration using our vast manufacturing capability to offer complete one source support
2006	•	Upgraded facility to support complete system integration Increased factory to 21,500 sq. ft. Increased factory personal by 30%
2007	•	Expanded our Marketing Department Shipped large chemical management system
2008	•	Manufactured a fully automated cleaning tool -One tool was 33' MAE cleaning tool with linear robot -One tool was 24' HF cleaning tool with linear robot Shipped 42,000 gal chemical containment system Shipped semi-auto nitride etch station to IBM
2009	•	Introduced solar tool for surface preparation Introduced "DryZone" dryer Designed Dry to Dry fully automated cleaning bench Designed and built Level 3 Bio-Hazard decontamination Sys. Developed chemical polishing and surface preparation process for local solar company
2010 – 2011	•	KCN Semi Auto Solar Plating Process -Multi panel design -2' x 5' oversized panels
2012	•	Tom Gross retires as CEO
2012 - 2013	•	Ozone precision cleaning technology. Ozone precision cleaning can now be sold in a new cleaning station or added as a cleaning process to your existing equipment.
2013 - 2014	•	Designed pre-diffusion clean station for 450mm wafers. This wafer reclaim process includes osculating Megasonic technology utilizing Kaijo's Quava Generators with logic control.
2015	•	Custom cleaning tool to support Linear Accelerator at Michigan State University
2016	•	Designed and shipped precision chemical delivery/mix system
2017	•	Introduced IPA Vapor Dryer with HF Etch Step
2018	•	16' Precision Cleaning Tool with Megasonic and N2 Hot dry
2019	•	10' Fully auto acid/solvent station with vertical auto safety barrier
2020	•	16' Fully auto large tube cleaner (tube size: 24'" dia. x 144" long)
2021	•	Survived COVID-19 and continue to grow
2022	•	Record sales.

Key Products and Services

- Broad-based product line in semiconductor wet process components
- Manufacturing flexibility by offering standard and custom products
- Highest standards in quality and service
- Worldwide sales and service representation

The success of this strategy has enabled Modutek to establish a leadership position in wet processing components and a strong business foundation with little dependence on outside investment or technology.

Broad-based Product Line - Modutek is the one component company that manufactures all wet processing components. Polypropylene, PVDF, quartz, Teflon® and stainless steel are the materials available, either in a static mode or with recirculation.

Process Stations – Manual, Semi-Auto, and Fully Automated. Etching, cleaning, plating, and solvent stations.

Custom Products - Modutek offers a wide range of standard products with a long list of available options. At Modutek we also pride ourselves on our ability to produce custom components that fit individual process requirements.

Megasonic Technology – Full line of high-frequency systems (430kHz, 950kHz and 2.0 MHz). Available in quartz for purity and high-temperature applications, PVDF, Stainless Steel, and Teflon. Easy installation for existing equipment.

IPA Vapor – Gradient type IPA Vapor dryer (Marangoni). Freestanding design or built-into wet station. No moving parts, No watermarks, No breakage, and very low particle adders.

Etch Bath Technology - Operator safety and process control are the two driving forces for the technology of Modutek's line of etch baths.

Neutralization, Air Scrubbers, Waste Water Treatment Systems and Chemical Delivery and Handling Systems – Continuous flow and batch ph neutralizers up to 250 GPM, fluoride treatment systems, solvent acid and heavy metal recovery systems, custom pack bed air scrubbers up to 25,000 CFM and Chemical Management with VMB's and controls

Rinse Bath Technology - Improving on one of our original product lines, Modutek is now able to offer rinse bath technology that produces a virtually contaminant-free environment. We have combined many innovative processes features with user-friendly and easily serviced components to improve the quality and efficiency of the wafer rinse process.

Filtration - Modutek has introduced many innovations into filtration with the aim of reducing acid consumption and particle counts while improving process yields.

Retrofit Technology - With a continuing need for increased wafer dimensions, Modutek offers over 17 years of expertise in retrofitting existing wet process stations with new components. Our skilled field service personnel work to ensure a smooth process transition.

Key Personnel

Douglas Wagner / CEO & President

- 46 years in the semiconductor industry
- Joined Modutek in 1987

Robert Brody / VP & Director of Operations

- 46 years in semiconductor process equipment
- Associated with Modutek since 1989

Remonda Gorgis/ Accounting

- 22 years in banking
- Joined Modutek in 2021

Joel Olvera / Inside Sales

- 34 years in the semiconductor Industry
- Joined Modutek in 1989

Mehrzad Sarvi / Field Service Manager

- 16 years-Equipment, Facility and Field Support
- Joined Modutek in 2022

Mitch Tojima / Director of Engineering

- 49 years in high technology
- Software programmer
- Joined Modutek in 2003

Anthony Rutland / Controls Engineer

- 10 years in high technology
- Software programmer
- Joined Modutek in 2015

Emilio Adriano / CNC Programmer

- 20 years of process station design experience
- Joined Modutek in 2017
- CNC programmer
- Solid Model Design

Martin Zapien / Mechanical Design

- 10 years in high technology
- Joined Modutek in 2022
- Solid Model Design

Mitchell Hartshorm / Mechanical Design

- 5 years in high technology
- Joined Modutek in 2022
- Solid Model Design

Marco Machuca / Mechatronic Design

- 2 years in high technology
- Software programmer
- Joined Modutek in 2022

Nick Nickhou / Consultant

- 18 years in high technology
- Joined Modutek in 2007